Electronic supplementary information

New Application of Carbon Quantum Dots in Memristor

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I Supporting Figures:



Figure S1. a) TEM images of carbon QDs liquid. b) AFM images of carbon QDs films in CMD. c) The fluorescent emission spectra of carbon QDs liquid. d) The UV visible absorption spectrum of carbon QDs liquid.



Figure S2. a) Endurance in different batches of PMD. b) Endurance in different batches of CMD. c) Forming program of PMD. d) Forming program of PMD.



Figure S3. a) Measured the endurance properties with 10 μ s pulse. b) CMD can achieve 10⁶ cycles.



Figure S4. a) Temperature dependence of I-V curves from 300K to 420K, b) Retention characteristics at 420K, c) Switching voltage statistics at different temperatures with error bar. d) HRS and LRS statistics at different temperatures with error bar.



Figure S5. Relationship between R/R_0 in LRS and temperature.



Figure S6. The single pulse group of eight continuous scans from positive and negative directions.

II Conduction mechanism of the CMDs

The tunneling current can be expressed as followed equation according to the TAT conductance theory ^{1,2}

$$I = N \bullet q \bullet v \tag{S1}$$

Here, N is the total number of traps that help conduct electricity, and v is the transition rate, which can be written as

$$v = v_0 \bullet f \bullet P \tag{S2}$$

Here, v_0 is the frequency factor, and $f = 1/[1 + \exp((E_b - E_t + F \cdot d)/kT)]$ is the electrons Fermi–Dirac distribution in interior of the electrode. E_b is the barrier heigh, and the product of the Boltzmann constant and temperature is kT. The transmission probability *P* is shown as

$$P = exp\left\{-\frac{4}{3\hbar qF}\sqrt{2m_c \left[E_t^{3/2} - (E_t - F \bullet d)^{3/2}\right]}\right\}$$
(S3)

Here, \hbar , q, F, d, E_t is the reduced Planck's constant, electronic charge quantity, electric field intensity, tunneling distance, and defect-trap energy below CB, respectively.³

III STDP learning function

$$\xi = \begin{cases} A_{+} \exp\left(-\frac{\Delta t_{post-pre}}{\tau_{+}}\right) & (\Delta t_{post-pre} > 0) \\ -A_{-} \exp\left(-\frac{\Delta t_{post-pre}}{\tau_{-}}\right) & (\Delta t_{post-pre} < 0) \end{cases}$$
(4)

where A_+ and A_- were defined as the maximum synaptic strength modification when $\Delta t_{post-pre}$ is near zero. τ_+ and τ_- are learning windows determining .

IV Simulates the PPF functions of biological synapses

Paired-pulse facilitation (PPF) phenomenon means an increase in the synaptic weight upon decreasing the interval between two continuous pulses. ⁴ The pulse waveform is shown in the inset of Fig. S7. And the PPF results is shown in Figure S7. The PPF ratio is defined by

$$PPF = \frac{G_2 - G_1}{G_1} \times 100\% = C_1 \times e^{\frac{-t}{\tau_1}} + C_2 \times e^{\frac{-t}{\tau_2}}$$
(6)

Here, G_1 and G_2 are the conductance values after the first and second pulses, respectively. ⁵ The two time constants can be fitted τ_1 (28 µs) and τ_2 (37 µs), which relevant to fast and slow

decaying terms, respectively. It can be found from the fitting equation that smaller interval can cause the memory effect reinforced, which agree with the biological synapse.



Figure S7. PPF characteristics of CMD and the waveform used for PPF measurement.

Device Structure	δ _{set/reset} <5%	STP to LTP to LTD transition	Number of STDP Types	Associative Learning	Digit or Face Recognition	Journal
Pd/ carbon QDs/Ga ₂ O ₃ /Pt	YES	\checkmark	4	\checkmark	\checkmark	This work
Ag/Ga ₂ O ₃ /PbS QDs/Pt	No	_	1	_	-	Adv. Mater., 2019, 1805284
Pt (Au)/ SiO _x N _y :Ag/Pt (Au)	No	_	2	-	-	Nat. Mater., 2017, 16, 101
Pt/STO/Nb-STO	_	\checkmark	2	_	-	Adv. Funct. Mater. 2017, 1704455
ITO/Al ₂ O ₃ NP:PI/Ag	No	_	_	\checkmark	-	Adv. Mater. 2017, 29, 1602890
Au/Nafion/ITO	_	_	2	_	\checkmark	Adv. Funct. Mater. 2019, 29, 1808783
Cu/pV ₃ D ₃ /Al	_	\checkmark	1	_	\checkmark	Nano Lett. 2019, 19, 839

V Table 1. Comparison between in Recent Three Years Artificial Memristors Synapses and This Work*

* Symbols " \checkmark " and "–" denote demonstrated and non-demonstrated functions, respectively.

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